

微機電系統簡介

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<http://mdl.pme.nthu.edu.tw>



前言



About MEMS



1 mm



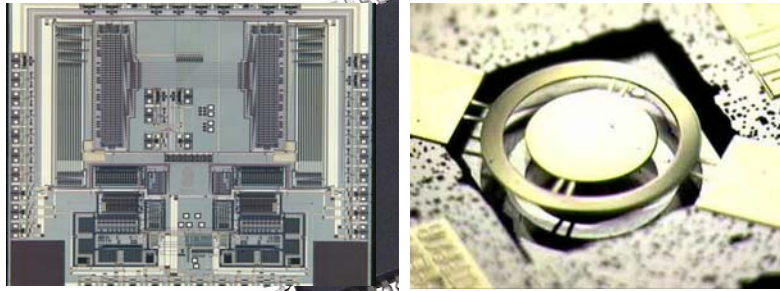
請大動機系微機電系統實驗室



What's MEMS

IC

MEMS



<http://www.aztex.biz/general-computer/integrated-circuit-work/>
Texas Instruments Inc.

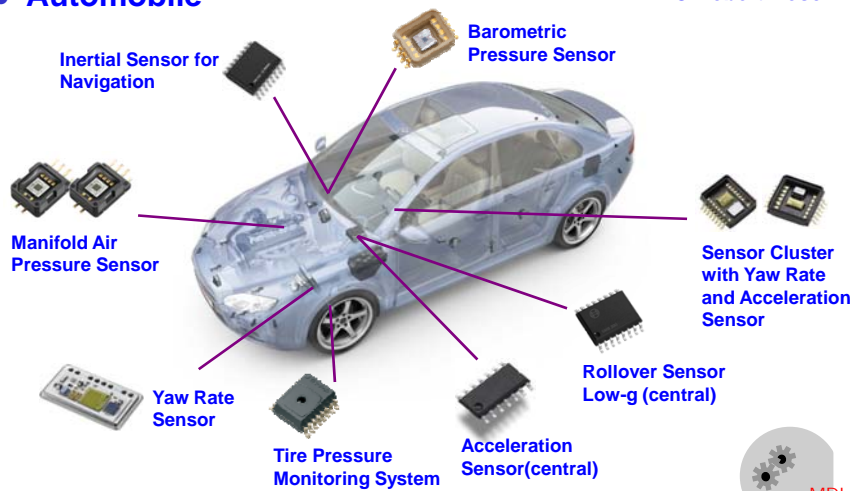
MDL



Where's MEMS

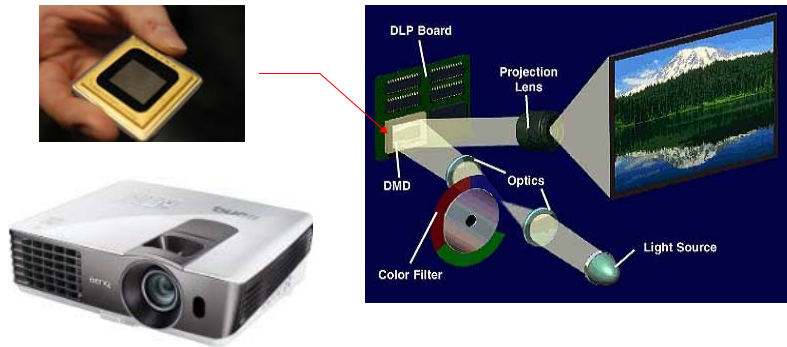
• Automobile

© Robert Bosch



Where's MEMS

- Before 2000 – inkjet printer, projector



Texas Instruments Inc.



Where's MEMS

- 2006~2013 – consumer electronics



Wii



Smart phone

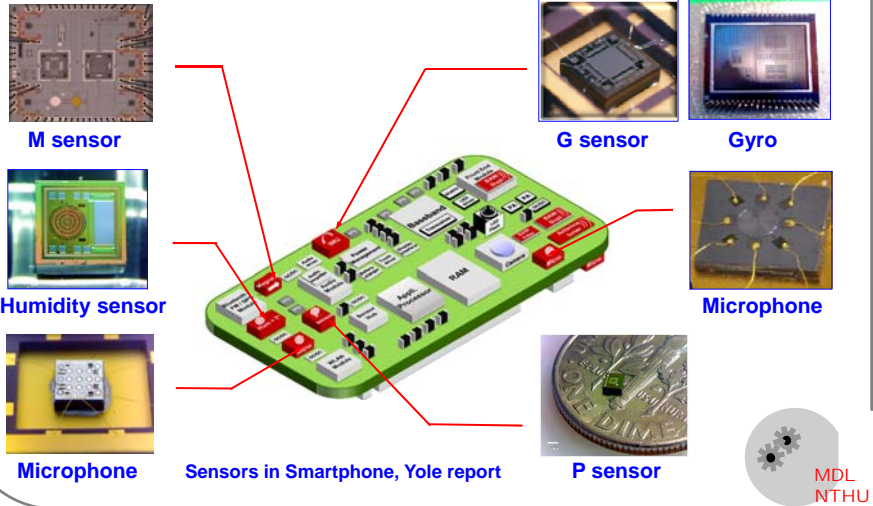


Wearable



Where's MEMS

- MEMS Devices in volume in 2013 (from Yole)



Where's MEMS

- Internet of Things (IoT)



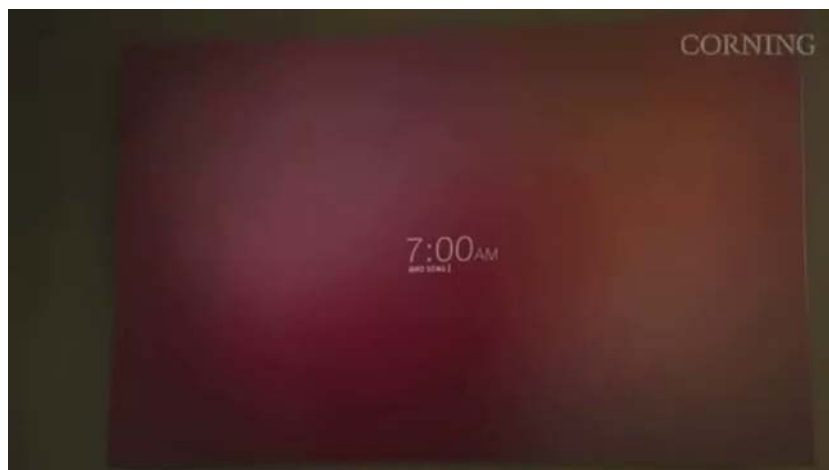
Corning - A Day Made of Glass



<http://www.corning.com/index.aspx>



Corning - A Day Made of Glass



<http://www.corning.com/index.aspx>



Parrot - Drone



<http://www.parrot.com/>



Parrot - Drone



<http://www.parrot.com/>



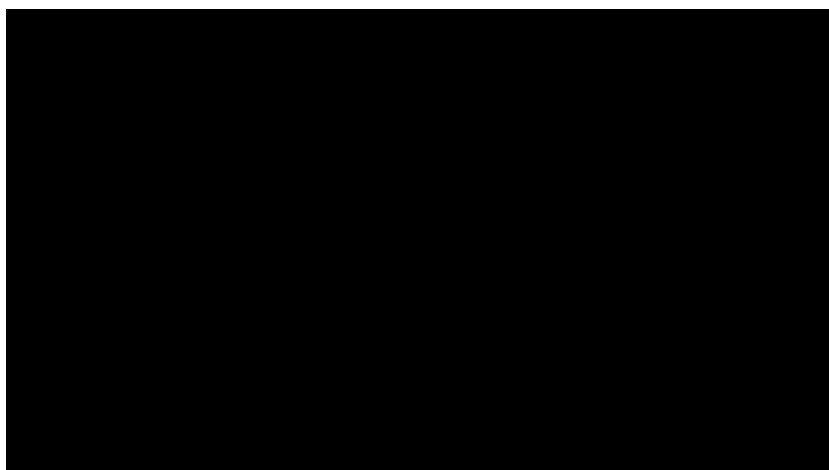
Adidas – Smart Ball



<http://micoach.adidas.com/>



Adidas - Smart Ball



<http://micoach.adidas.com/>



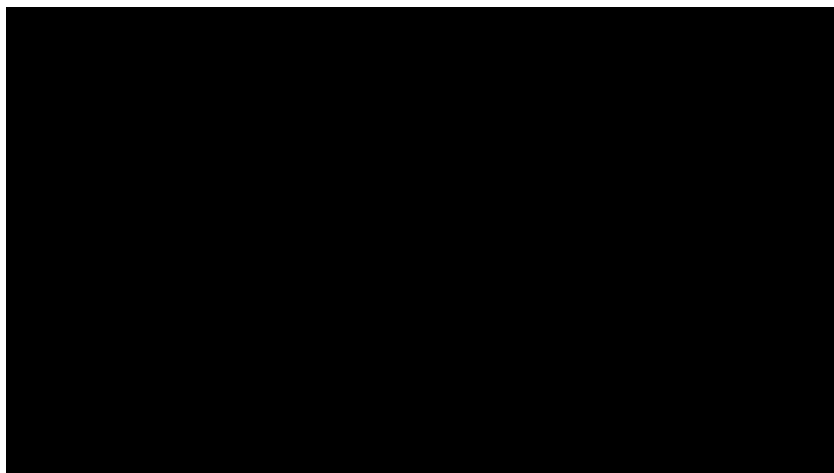
Bragi – Smart Earphone



<http://www.bragi.com/>



Bragi – Smart Earphone

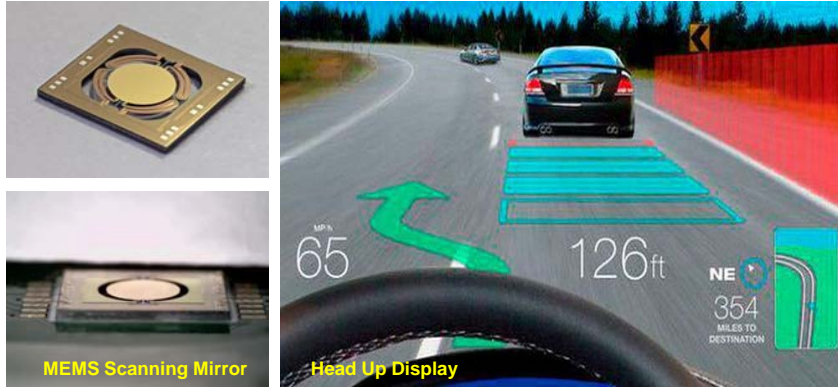


<http://www.bragi.com/>



MEMS Scanning Mirror

- AR HUD, also for AR Glasses of Metaverse



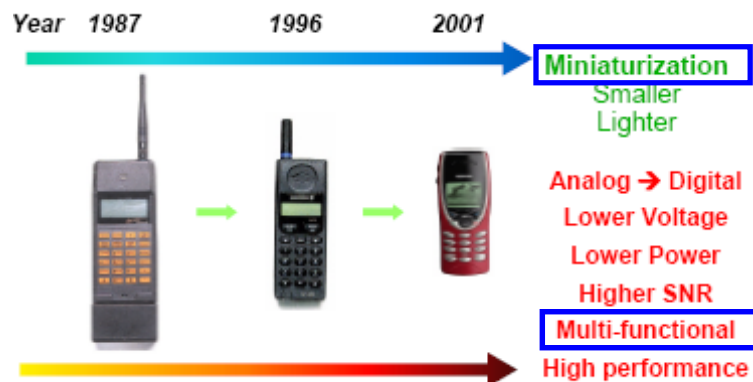
Cheng, Liu and Fang, 2022

<https://reurl.cc/EzozDv>



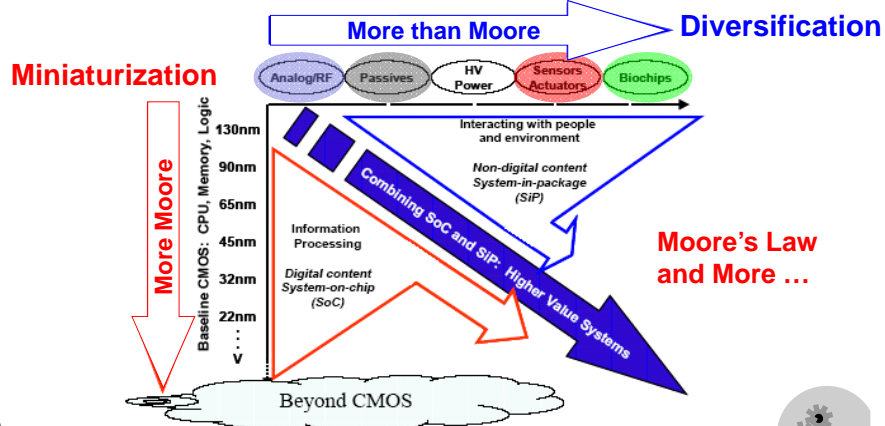
Why MEMS

- Small and Smart



Why MEMS

- Small and Smart
- Add value to the existing CMOS tech



Source: ITRS Roadmap 2005, www.itrs.net



平面加工技術

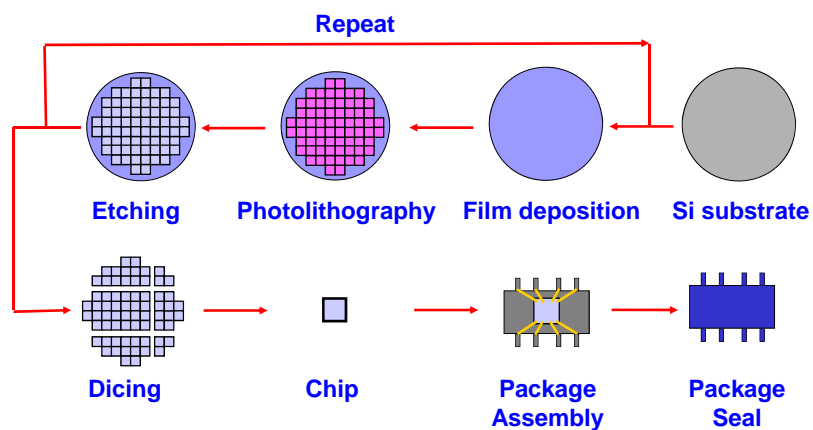


Planar Technologies

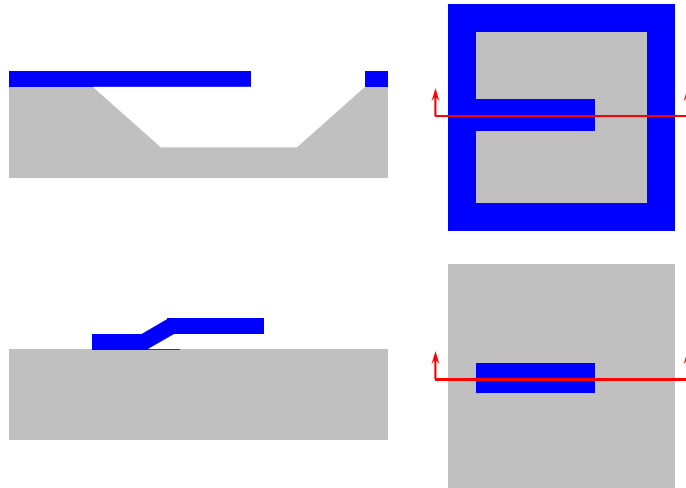
- IC : TSMC, UMC, Vanguard, ...
- LED/VCSEL/Diode laser : Liteon, Epistar,...
- TFT-LCD : AUO, Chimei-Innolux, ...
- Magnetic recording head : Seagate, WD, ...
- MEMS : TSMC, UMC, APM, ...



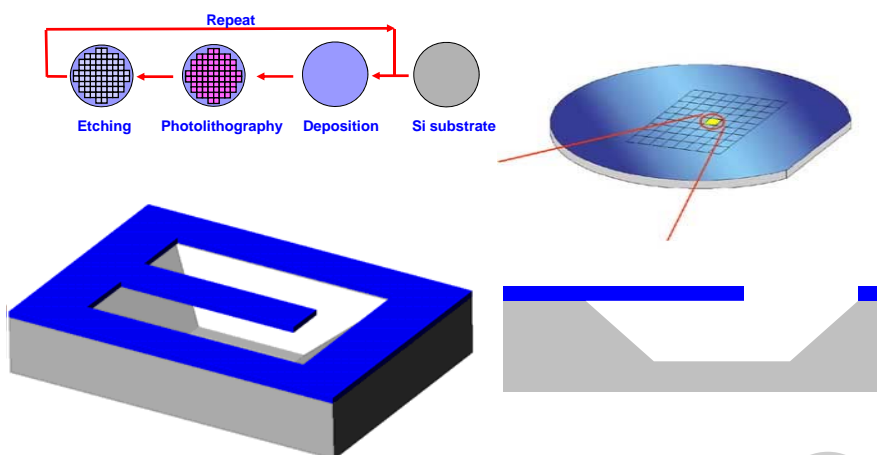
Semiconductor processes



Suspended MEMS Structures

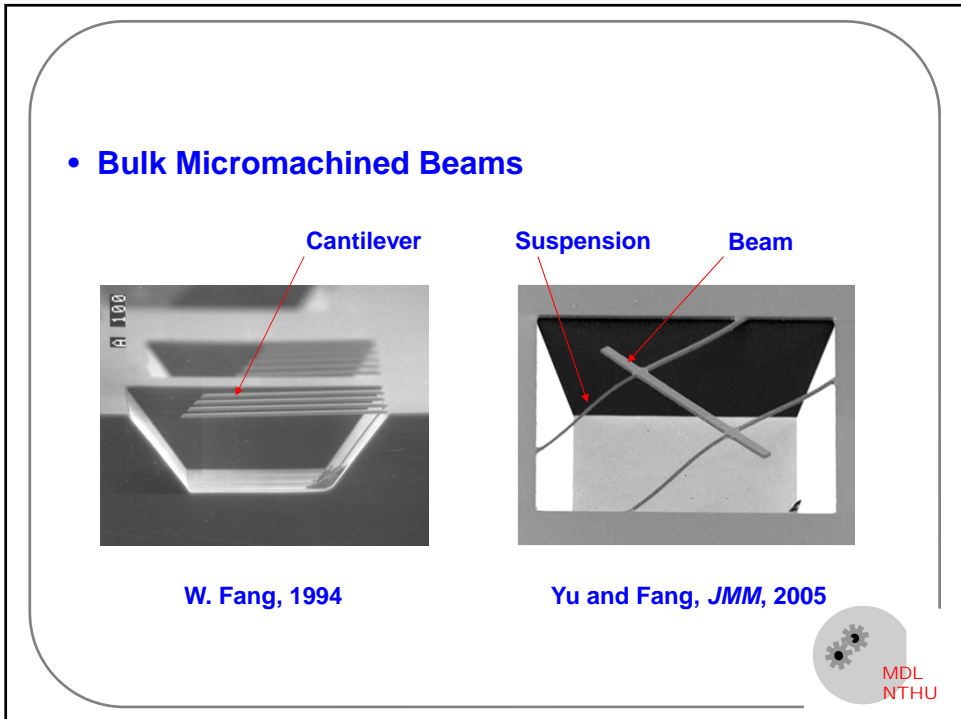
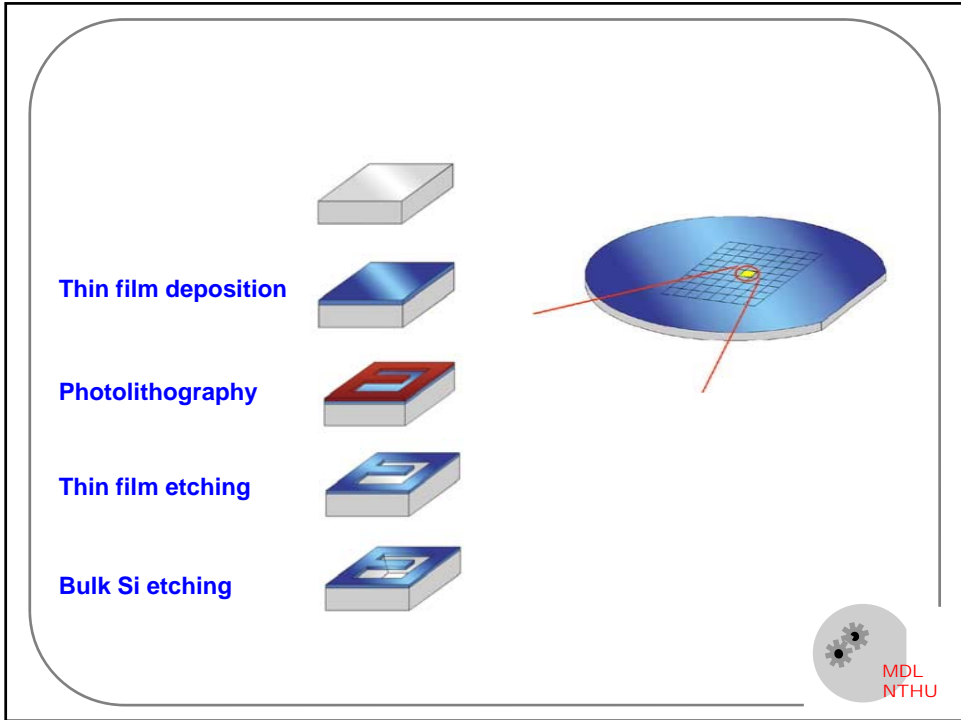


Bulk Micromachining

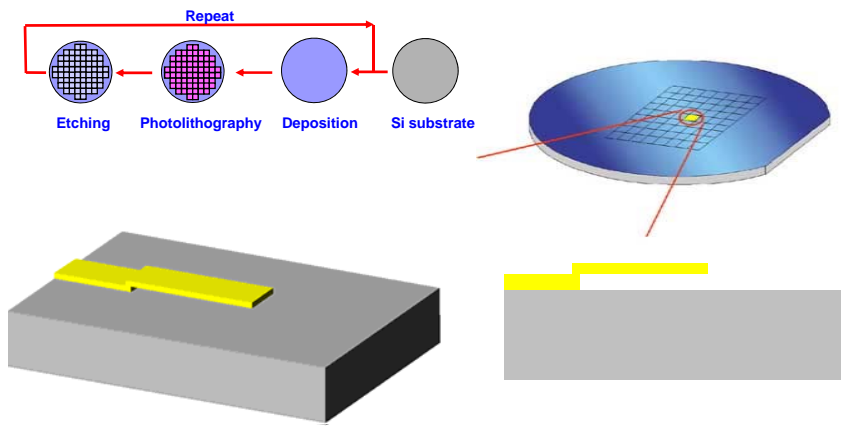


MEMS Manufacturing Technology





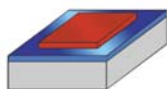
Surface Micromachining



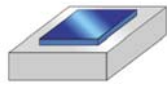
Lithography and Etching



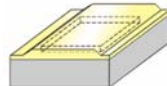
Photolithography



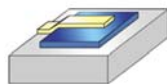
1st film etching



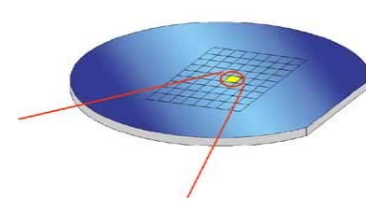
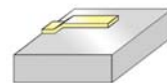
2nd film deposition



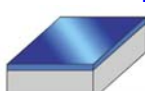
Photolithography & 2nd film etching



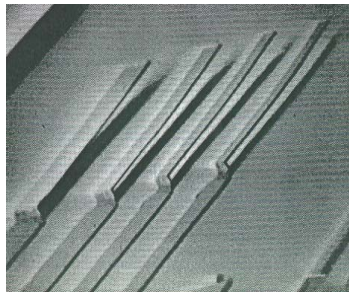
1st film removing



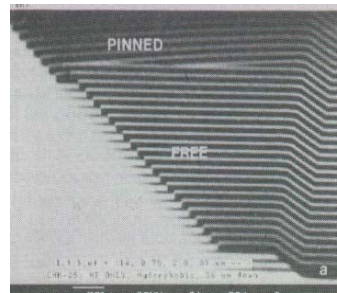
1st film deposition



- **Surface Micromachined Beams**



Howe and Muller, 1983



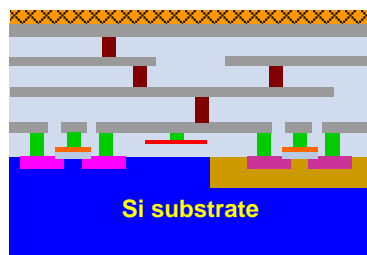
Mastrangelo and Hsu, 1993



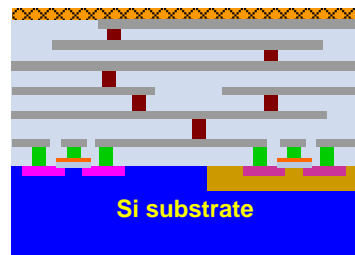
Semiconductor Devices

- **Examples: by CMOS processes at TSMC, UMC, etc...**

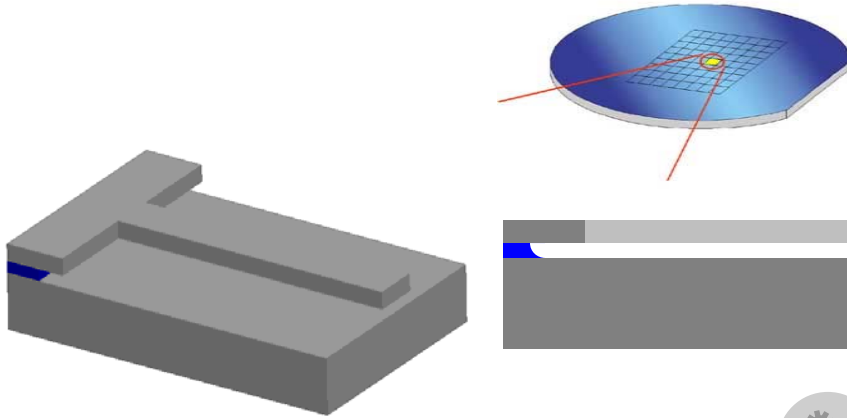
0.35 μm 2P4M CMOS process



0.18 μm 1P6M CMOS process



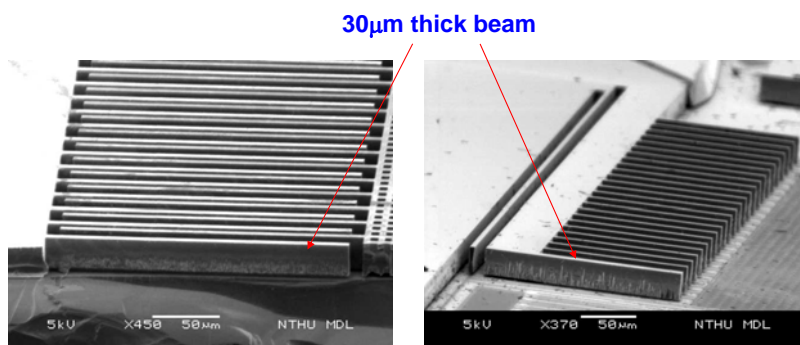
SOI Micromachining



SOI patterning



- SOI Micromachined Beams



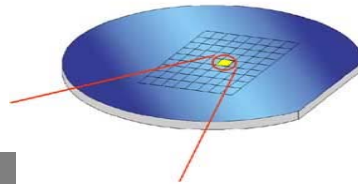
MDL



Cavity SOI Micromachining



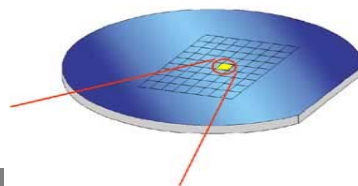
BUSSING

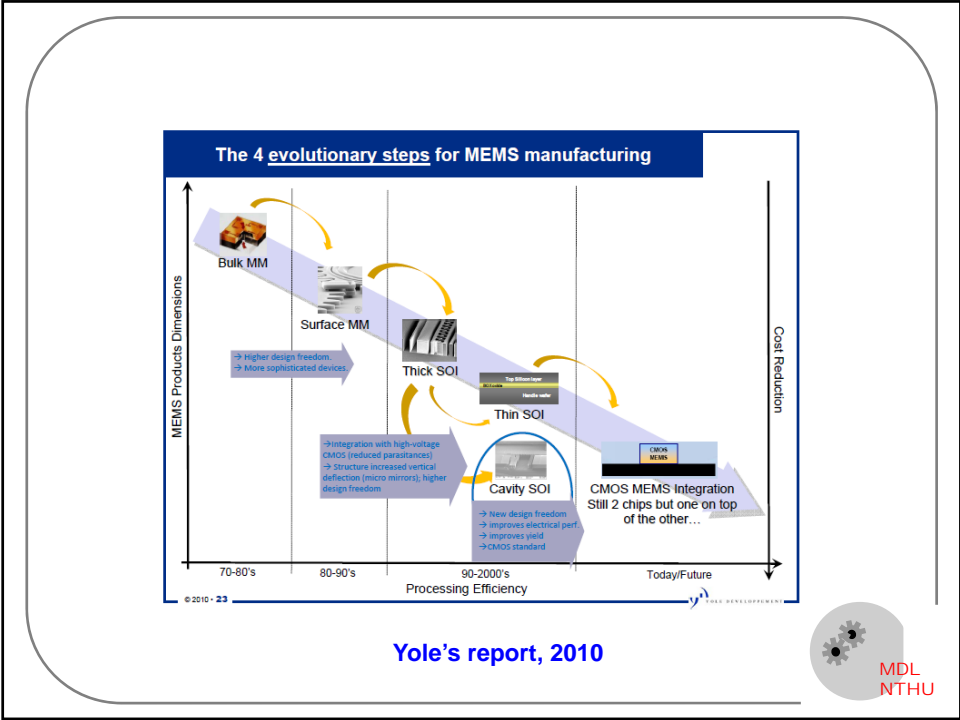


CMOS SOI Micromachining



BUSSING





關鍵元件

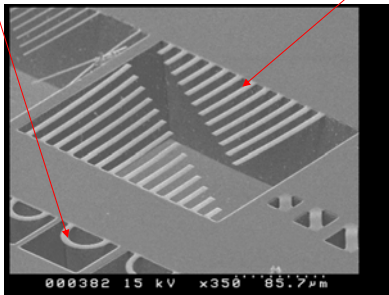
MDL NTHU

Passive component

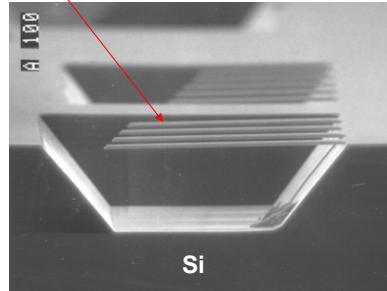
- Cantilever, suspension - springs

Semi-circular suspension

Cantilever



T. Tzou and W. Fang, 1999



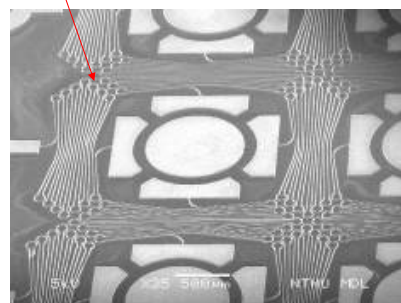
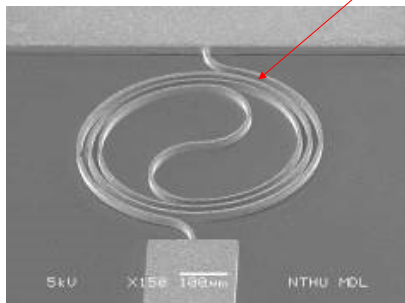
W. Fang, 1994



Passive component

- Curved beam - spring

Curved beam

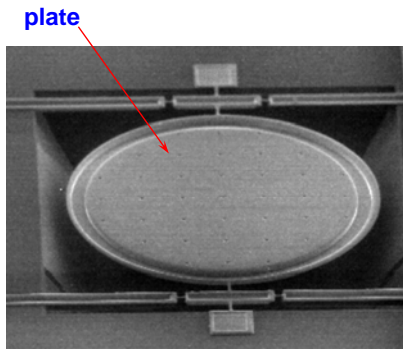


W.-L. Sung and W. Fang, 2014

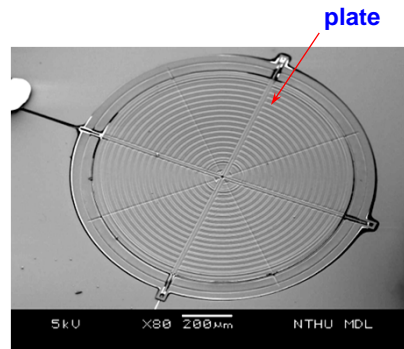


Passive component

- Plate – rigid mirror, flexible diaphragm (microphone)



H.-Y. Lin and W. Fang, 2000

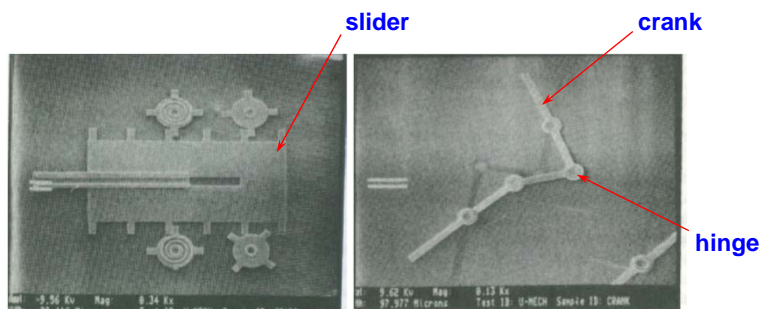


C.-K. Chan and W. Fang, 2011



Passive component

- Slider, hinge, cranks

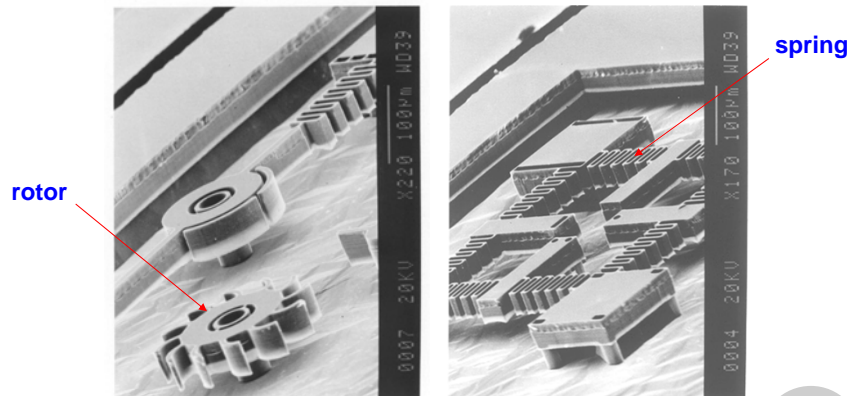


L.-S. Fan, et. al., IEEE Transaction on ED, 1988



Passive component

- Gear, rotor, linkage

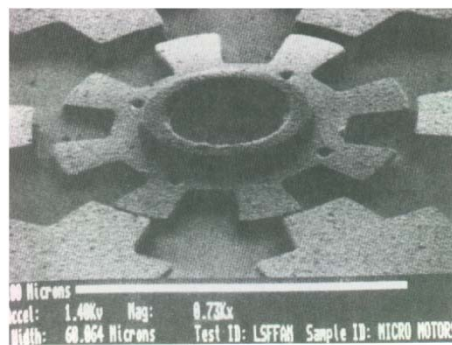


J. Hsieh and W. Fang, 2000



Active component

- Angular electrostatic actuator - motor

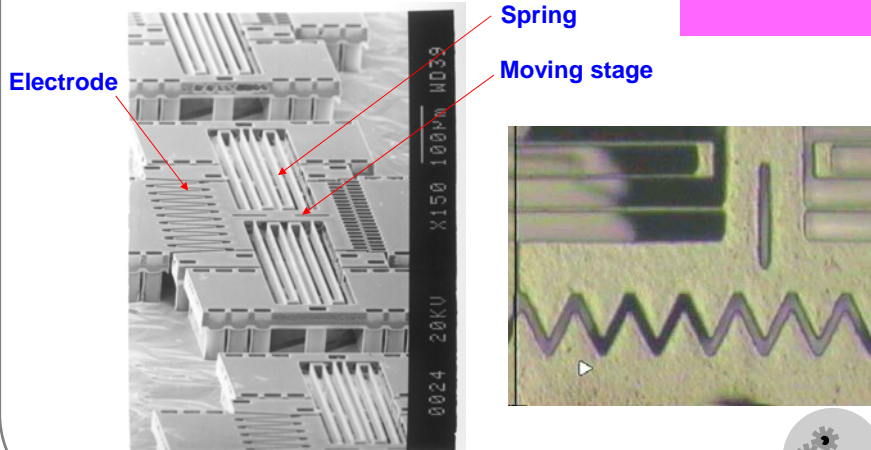


L.-S. Fan, et.al., Int. Electron Devices meeting, 1988



Active component

- Linear electrostatic actuator

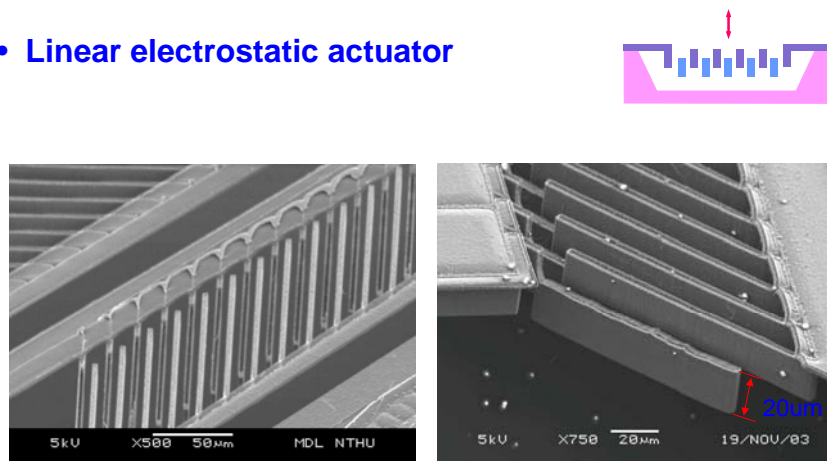


J. Hsieh and W. Fang, 2000



Active component

- Linear electrostatic actuator

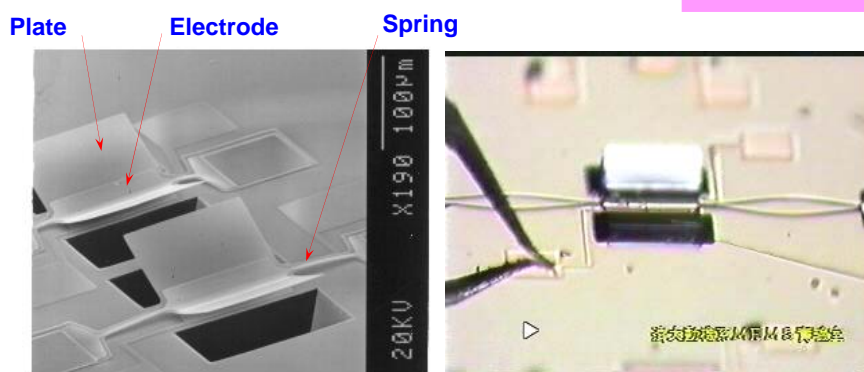


M. Wu and W. Fang, 2005



Active component

- Angular electrostatic actuator

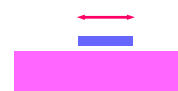
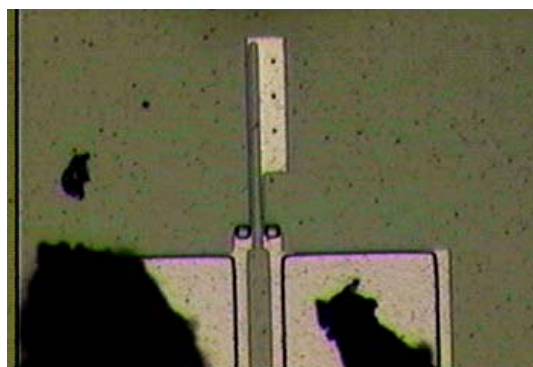


J. Hsieh and W. Fang, *Sensors and Actuators A*, 2000



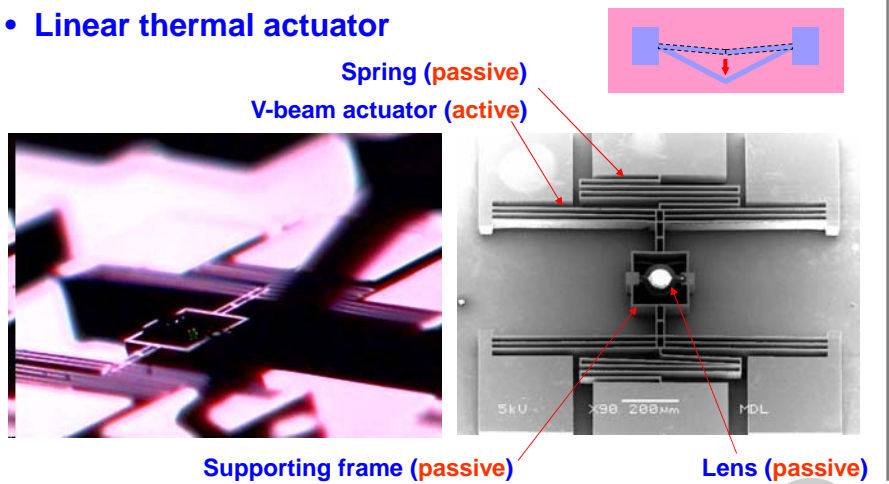
Active component

- Linear thermal actuator



Active component

- Linear thermal actuator

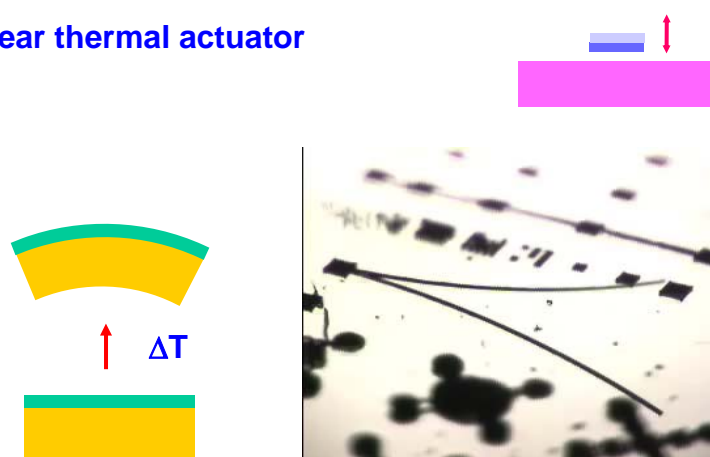


C. Lai, J. Hsieh, and W. Fang, *IEEE Optical MEMS'04*, 2004



Active component

- Linear thermal actuator

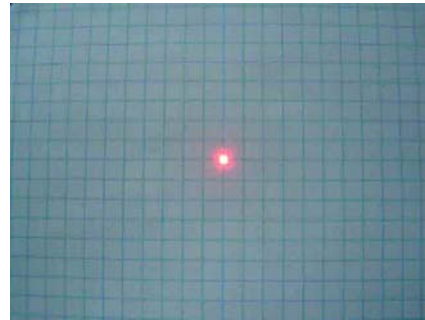
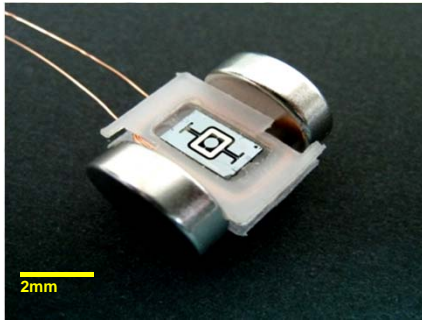
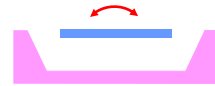


W.-K. Hsu, and W. Fang, *Nanotech*, 2008



Active component

- Angular magnetic actuator



Yang, and Fang, *JMEMS*, 2007



組裝與整合



About Mechanical Device



<https://www.patek.com/>



About Mechanical Device



<https://www.patek.com/>



Assembly



www.precisionscalereplicas.com

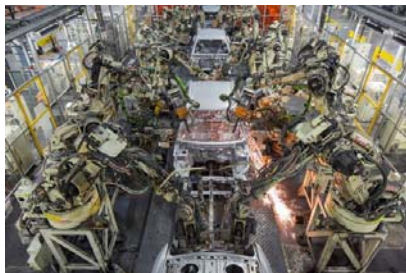


www.kukausa.com



Assembly

- Toyota and Foxconn assembly lines



www.youngertoyota.com



www.zaeke.com



Assembly

- Boeing 777 assembly lines



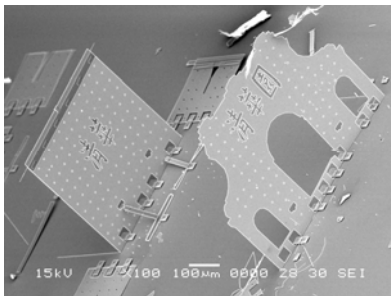
www.ainonline.com



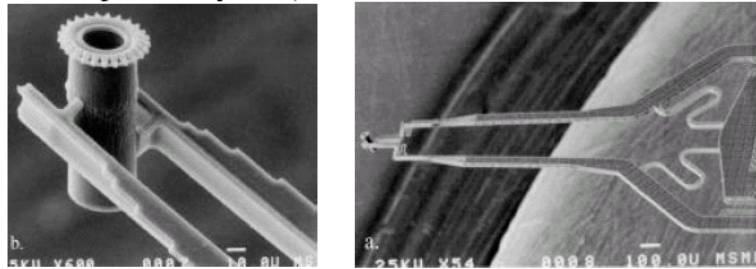
www.flightglobal.com



- Manually assembled by probe



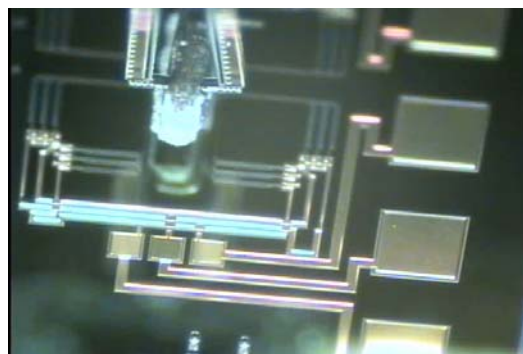
- **Manually assembled by micro gripper**



Keller, UC Berkeley, 1998



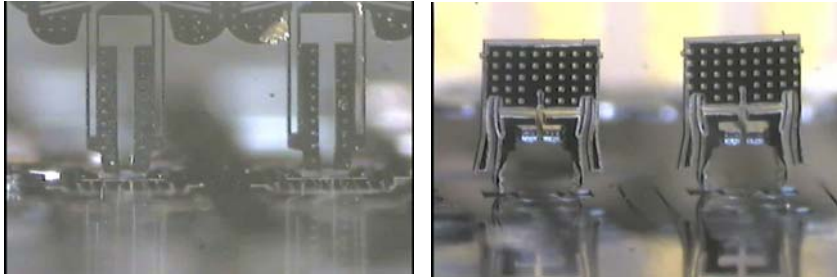
- **Automatically assembled by precision machine**



Zyvex Inc.



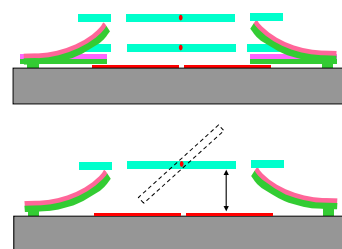
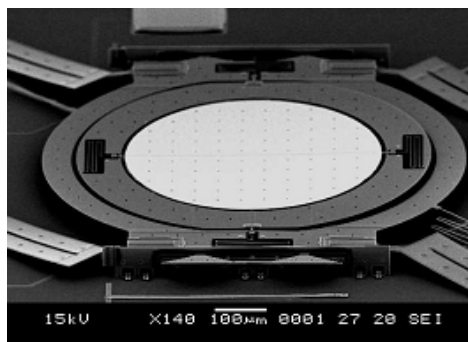
- Automatically assembled by precision machine



Zyvex Inc.

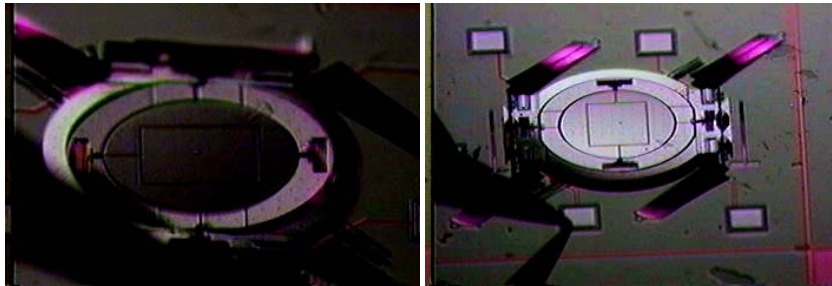


- Self assembly by residual stress deformed beam



Y.-P. Ho, M. Wu, H. Lin, and W. Fang, *IEEE Optical MEMS '02*, 2002



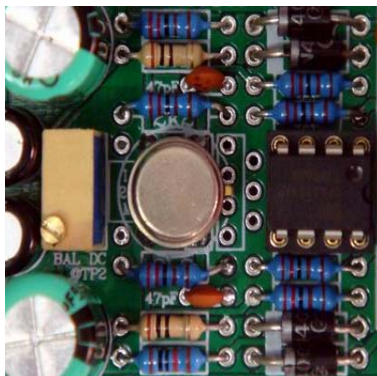


Y.-P. Ho, M. Wu, H. Lin, and W. Fang, *IEEE Optical MEMS '02*, 2002

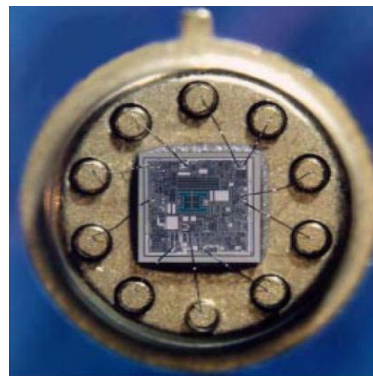


Process Integration

- **Discrete vs Integrated** electronics components



ATM Elektro, Czech Republic



ADI, USA



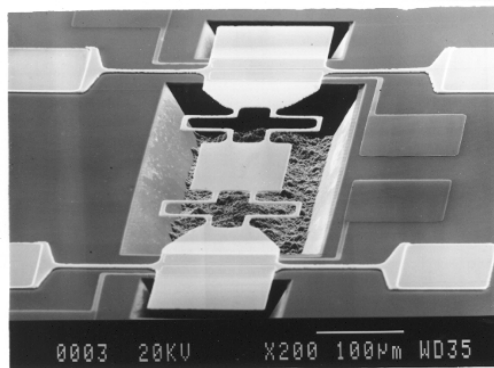
- **Assembly by process integration (一體成形)**



Brigham Young Univ., USA



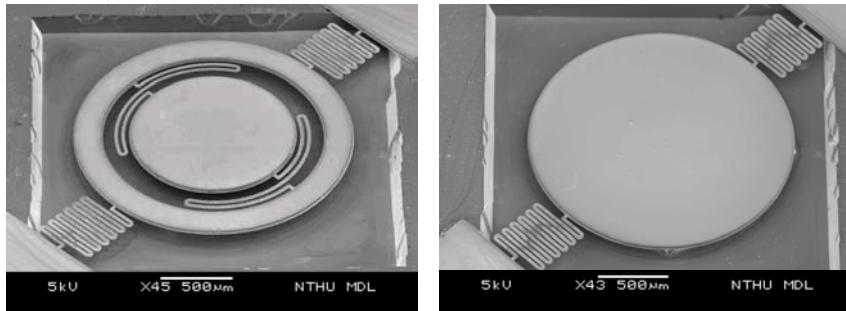
- **Assembly by process integration**



J. Hsieh and W. Fang, *Transducer'99*, 1999



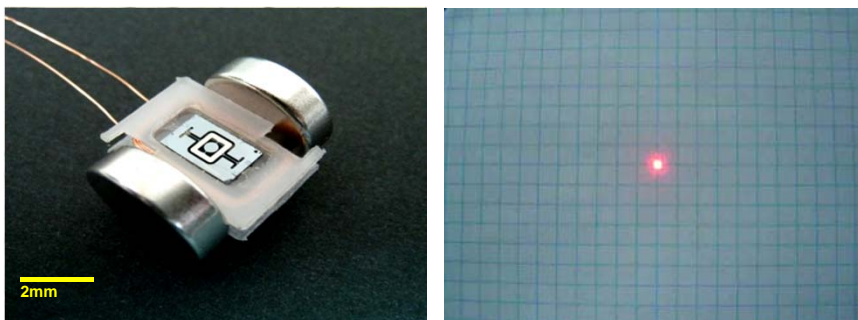
- Assembly by process integration



H. Yang, and W. Fang, *IEEE MEMS'06*, Istanbul, Turkey, 2006



- Scanning images



Yang, and Fang, *JMEMS*, 2007



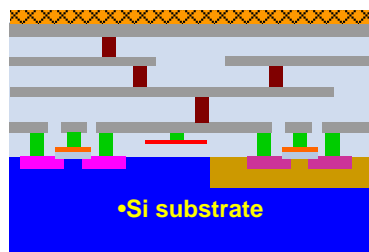
製程平台 - 標準製程



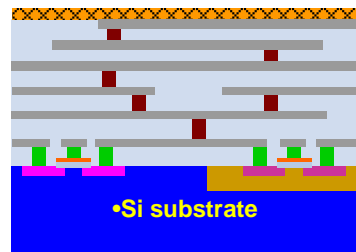
Standard CMOS Processes

- Available in CMOS foundries: TSMC, UMC, etc...

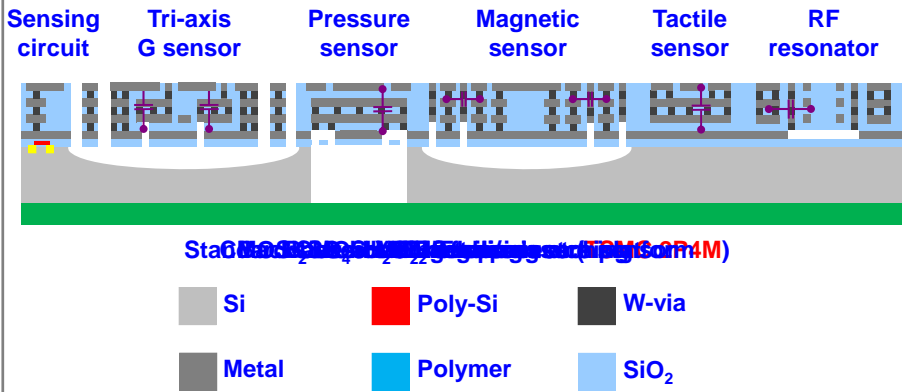
0.35 μ m 2P4M CMOS process



0.18 μ m 1P6M CMOS process



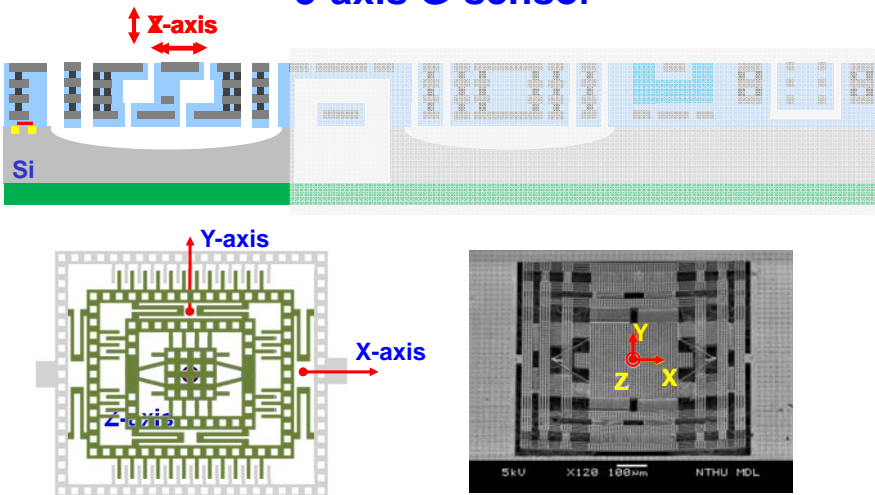
CMOS-MEMS Platform



- Standard TSMC 0.35μm 2P4M CMOS process
- Post-CMOS processes developed by Prof. Fang's group



3-axis G-sensor

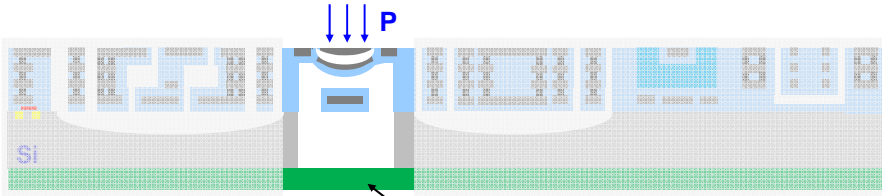


Single Z-axis mass

Sun, and Fang, *IEEE MEMS*, 2009
 Sun, and Fang, *IEEE Trans. on ED*, 2010

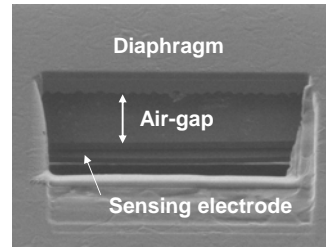
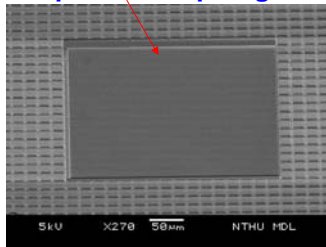


Pressure Sensors



Suspended diaphragm

Packaging



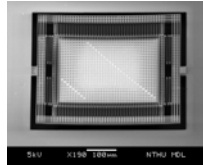
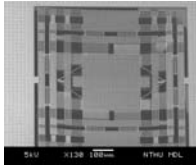
FIB sectioning

Sun, and Fang, *Transducers*, 2009
Sun, and Fang, *JMM*, 2009



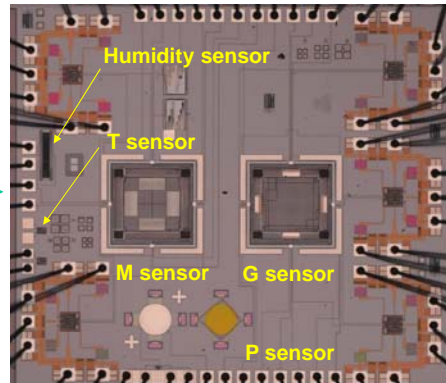
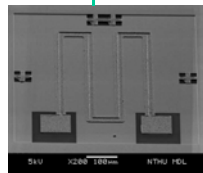
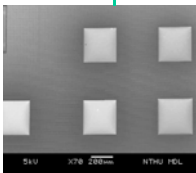
3-axis G Sensor

M Sensor



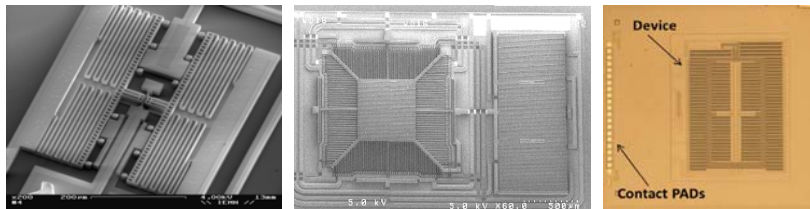
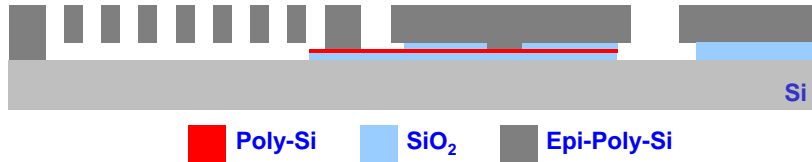
P Sensor Array

T Sensor



STM THELMA Platform

- Thick Epi-poly Layer for Microactuators and Accelerometers

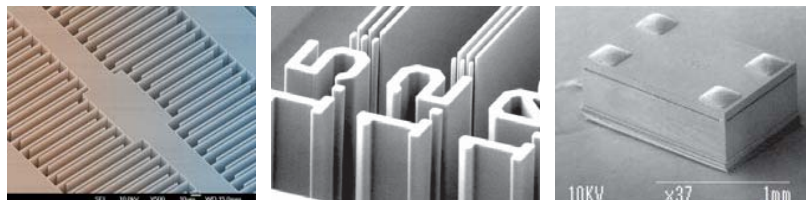
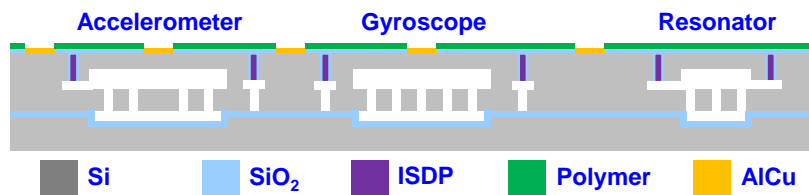


<http://www.st.com/>
G. Langfelder et al., *IEEE Trans. on IE*, 2012



Teledyne DALSA MIDIS Platform

- MEMS Integrated Design for Inertial Sensors

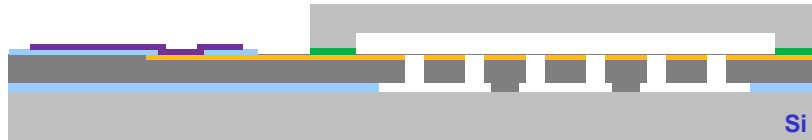


<http://www.teledynedalsa.com/>

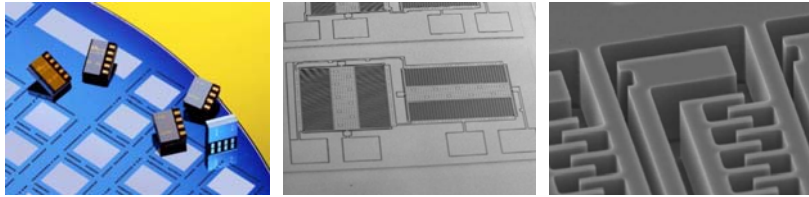


Tronics Platform

- Epi-SOI technology



Epi-Si
 SiO₂
 Implant
 Metal
 Polymer

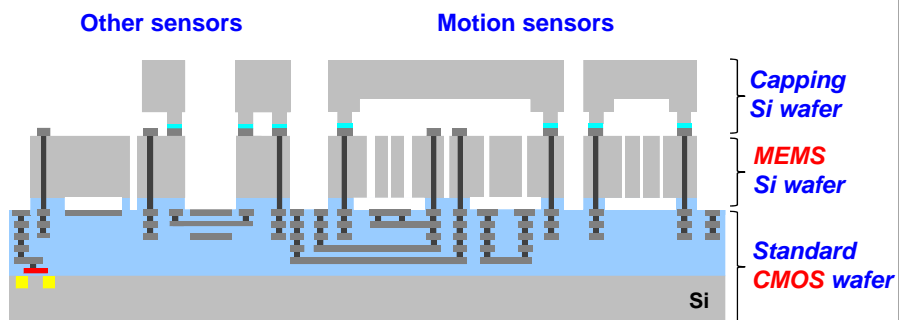


<http://www.tronicsgroup.com/>
 S. Renard, *JMM*, 2000



TSMC MEMS Platform

- Si-MEMS above CMOS



SiO₂
 Poly-Si
 W-via
 Metal

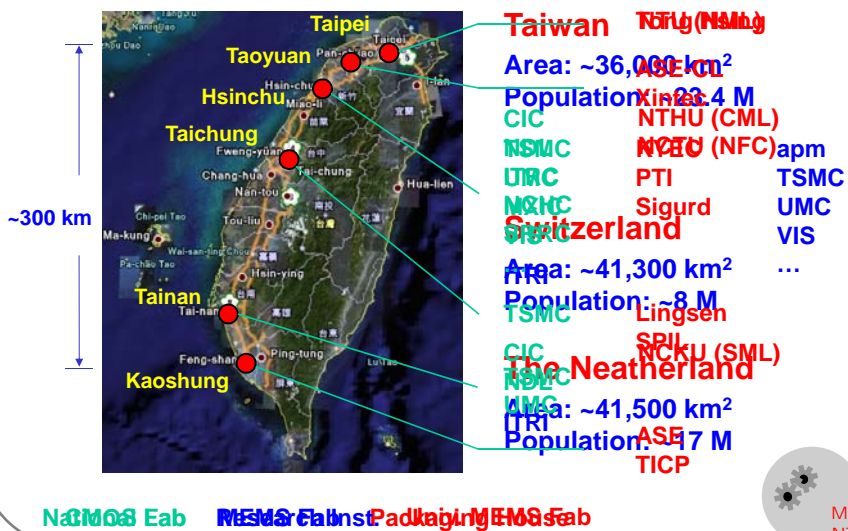
Source : TSMC



台灣現況簡介



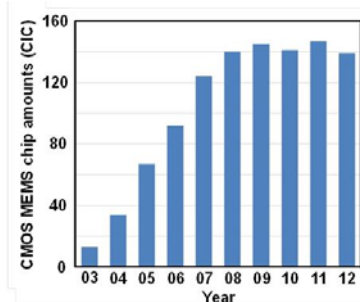
MEMS Eco-system at Taiwan



National Lab – CIC (TSRI)



- **CIC: Chip Implementation Center, since 1993**
- **CMOS MEMS Processes**
 - + 0.35 μ m 2-Poly 4-Metal **TSMC** process (from 2002, 4 runs/year)
 - + 0.18 μ m 1-Poly 6-Metal **TSMC** process (from 2006, 4 runs/year)
 - + 0.18 μ m 1-Poly 7-Metal **UMC** process (from 2013, 2 runs/year)
- **APM post-CMOS Process to release MEMS designs**



Source : CIC



National Lab – NDL (TSRI)



- **NDL: Nano Device Laboratories, since 1988**
- **NDL has been dedicated to:**
 - + Support academic research
(More than 70 equipments are opened to students)
 - + Frontier IC/MEMS technology development
 - + Bridging the academic and industry



Clean room areas (m²)

Class 10	370
Class 1,000	250
Class 10,000	1525
Facilities area	1420



Nonprofit Research Org - ITRI

- ITRI: **I**ndustrial **T**ech. **R**esearch **I**nst., since 1973
- Manpower: ~6,000
+ ~200 MEMS engineers/researchers
- **M**icrosystems **T**ech **C**enter: **M**EMS total solution
- **P**ilot-run **M**EMS **F**ab: **M**EMS/post-CMOS processes



MEMS clean room areas (m²)

Class 10	N/A
Class 1,000	260
Class 10,000	390
Facilities area	360

Source : ITRI Southern Region Campus



MEMS Networks at Taiwan



Design Cluster

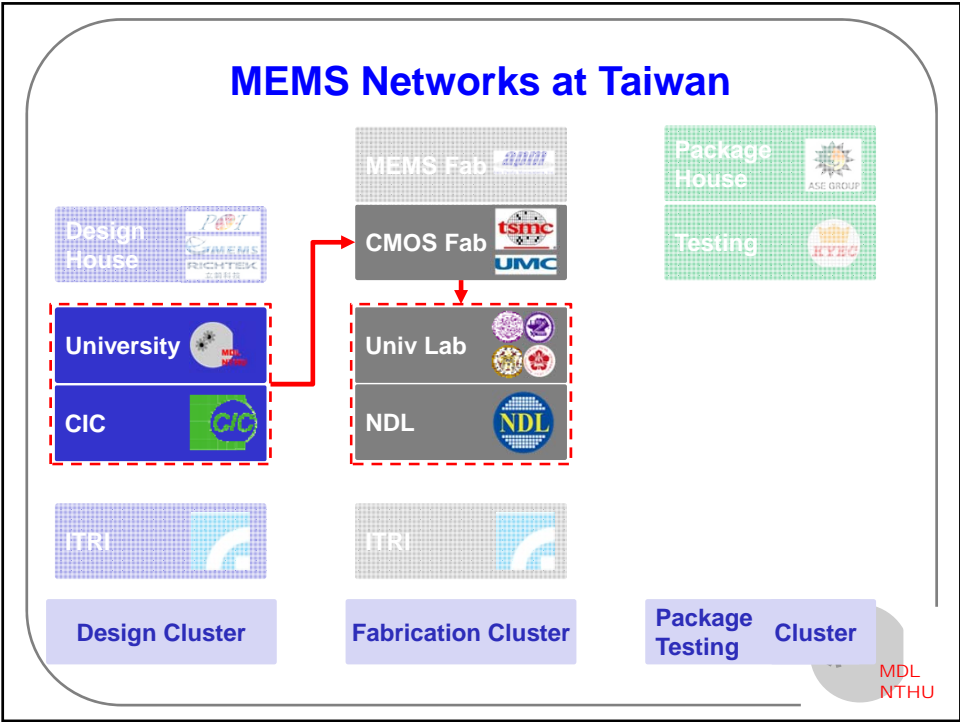


Fabrication Cluster



Package Testing Cluster





0.18um 1P6M TSMC CMOS Process

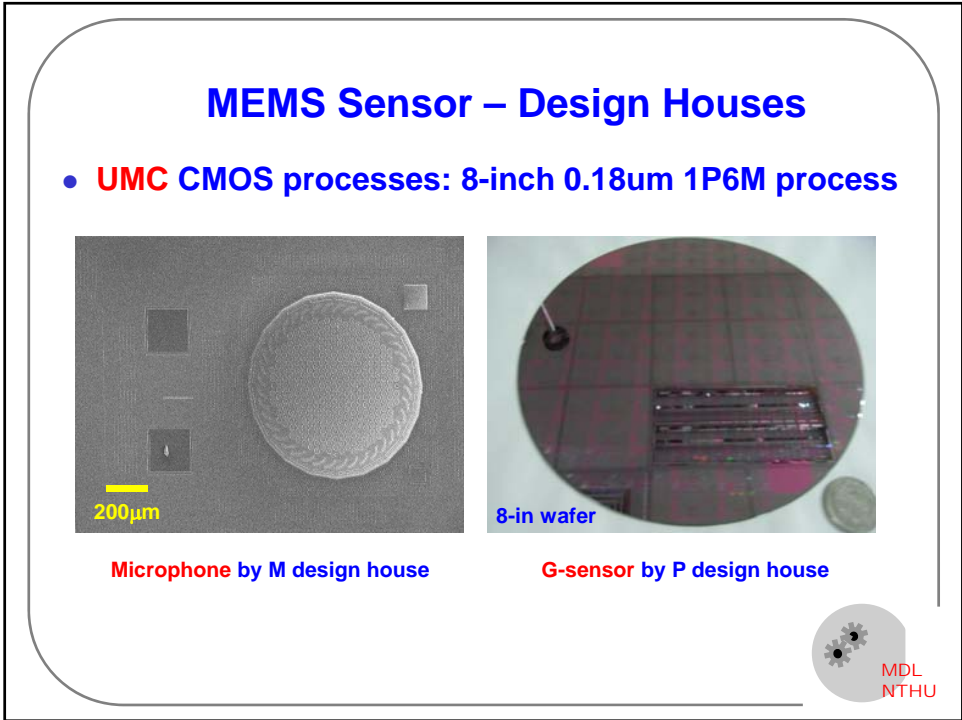
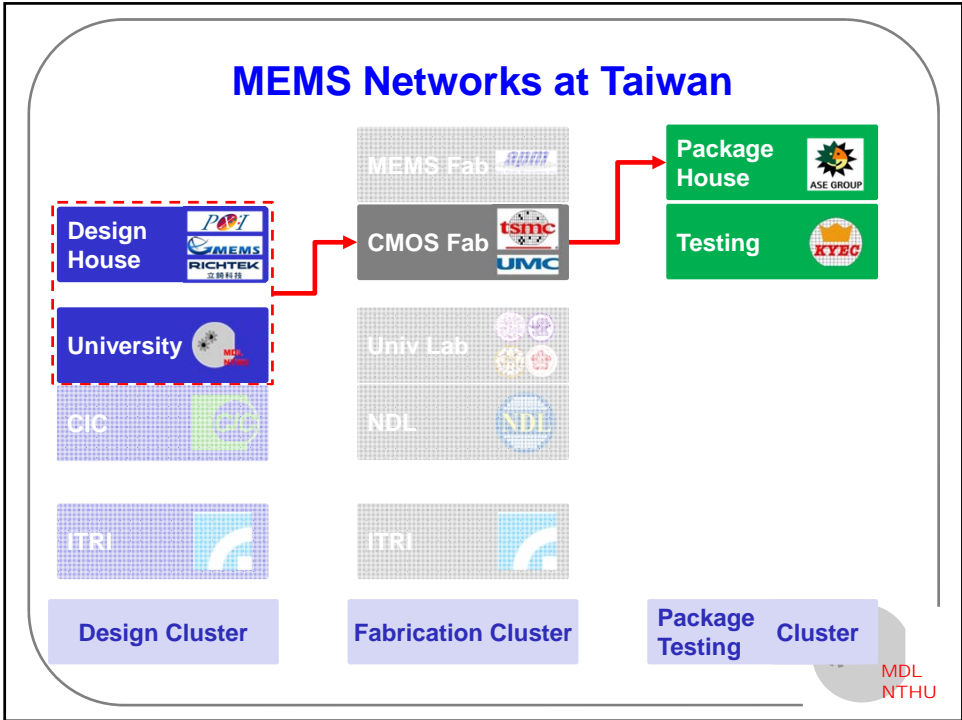
SKU X220 100um MDL NTHU

3-axis accelerometer

Sensor after bonding

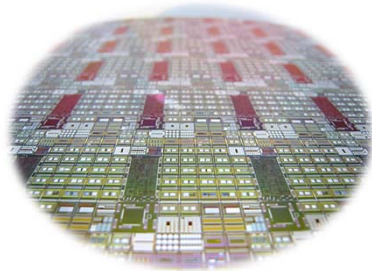
Sensing-axis	X-axis	Y-axis	Z-axis
Measurement Range (G)	0.01~1	0.01~1	0.01~1
Sensitivity (mV/G)	14.2	14.6	8.0
Non-linearity (%)	3.0%	1.5%	1.8%
Noise (mG/sqrtHz)	1.9	2.9	3.4

MDL
NTHU

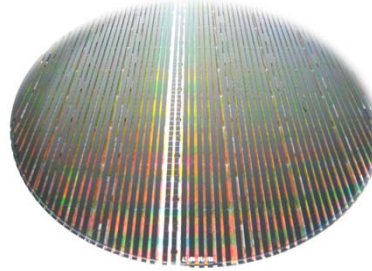


MEMS Sensors - Ecosystems

- **CMOS MEMS sensors on 8-inch wafer**
- **Eco-systems: ITE/Univ - UMC - SPIL - KYEC**



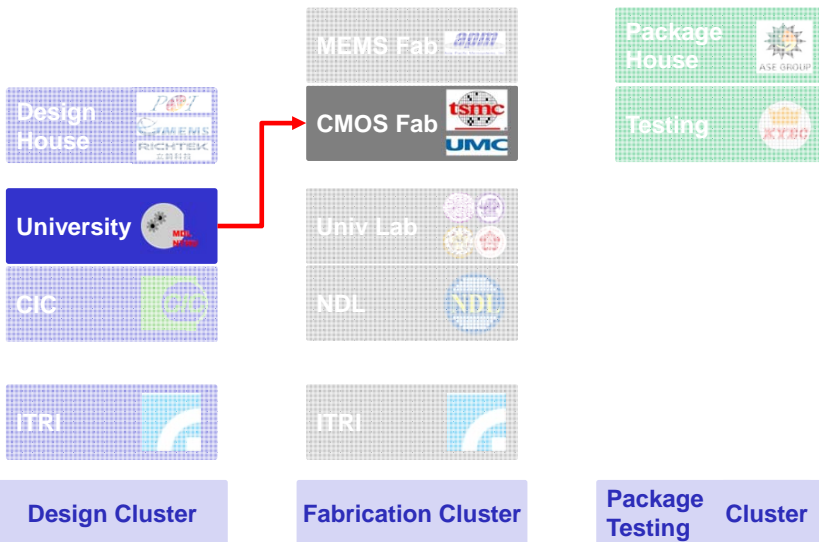
CMOS MEMS on 8" Wafer



Capped CMOS MEMS Sensors

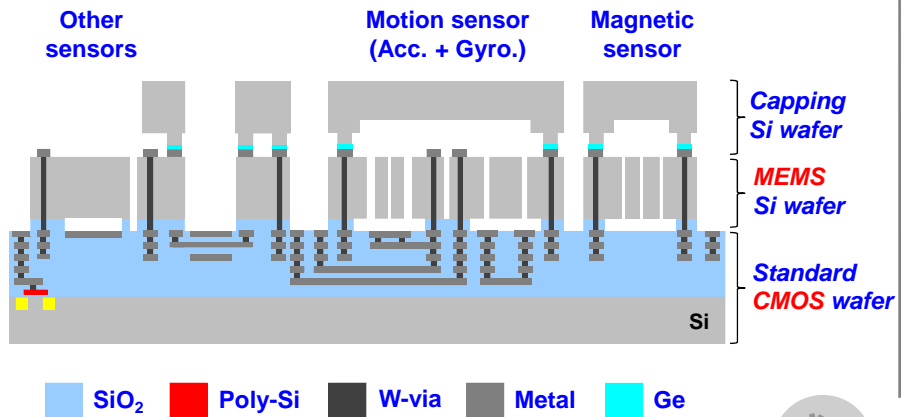


MEMS Networks at Taiwan



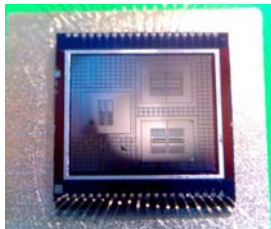
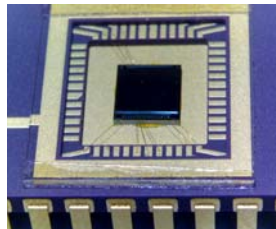
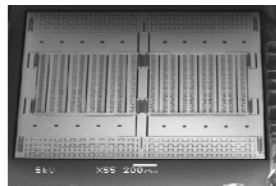
TSMC MEMS Platform

- **Si-MEMS above CMOS**



TSMC MEMS Platform

- **Gyroscope and Magnetic Sensor**

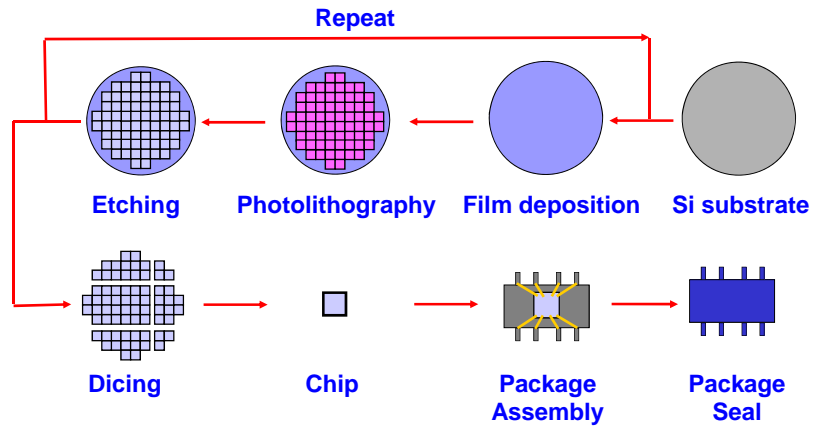


Lee and Fang, *IEEE MEMS*, 2016

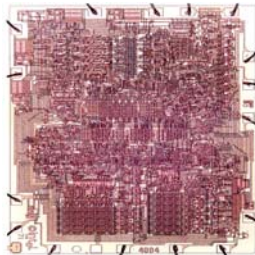
Sung and Fang, *IEEE MEMS*, 2016



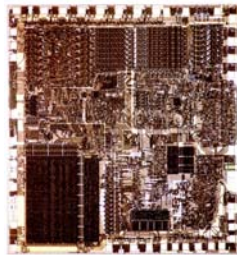
Semiconductor processes



Microprocessor



The 4004 – **2.3k** transistors, 1971



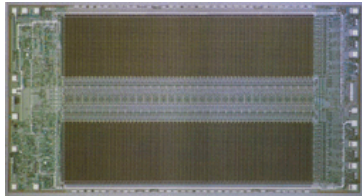
8088/8086 - **29k** transistors, 1978



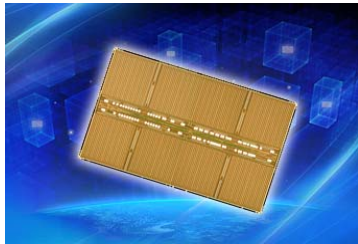
Pentium IV – **42M** transistors, 2000



Memory



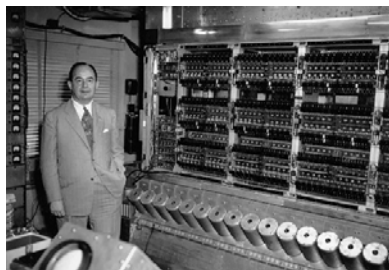
The 16kb DRAM, 1976



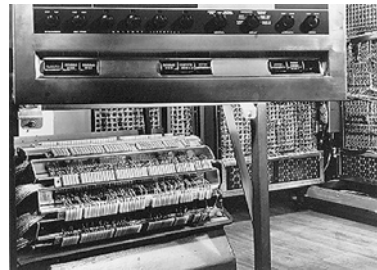
The 2Gb DRAM, 2011



Computer



von Neumann and his
"computer", 1952



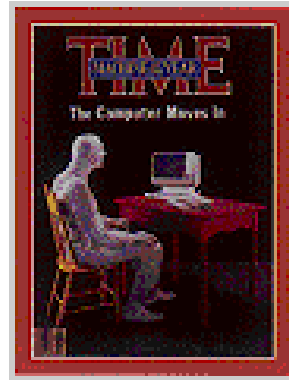
IBM 650, 1954



Computer



Jobs & Wozniak with Apple II - 1976



IBM PC – 1981/2



Computer

ENIAC (Vacuum tube)



Mainframes (LSI)



Notebook



Tablet



1946

1960

1965

1975

1992

2004

2010



First Mainframes
(Transistor)



Person computer
(VLSI)

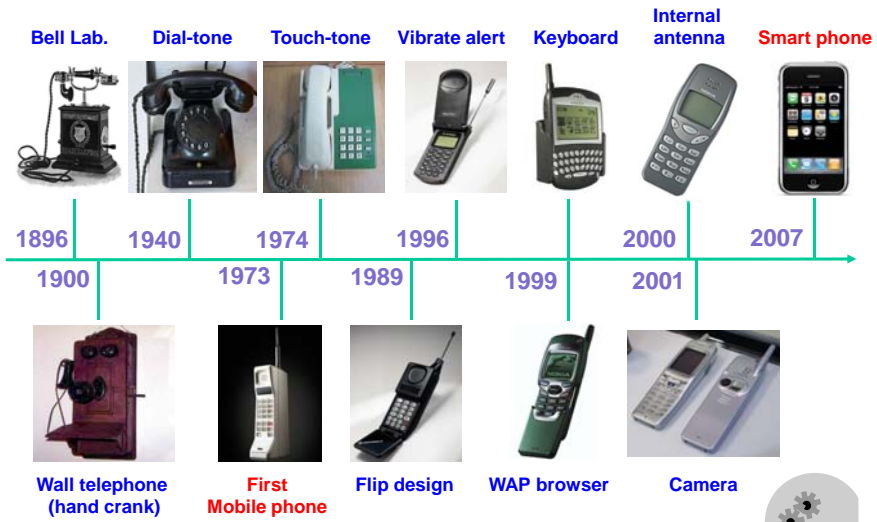


Notebook

Ref: Wiki



Telephone



Ref: Wiki

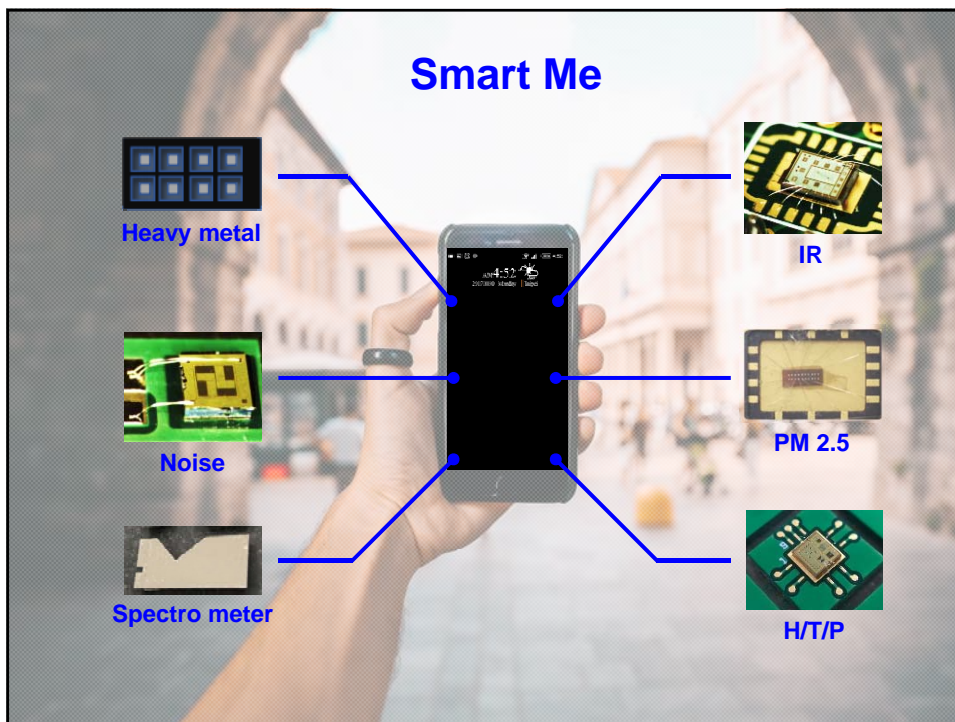
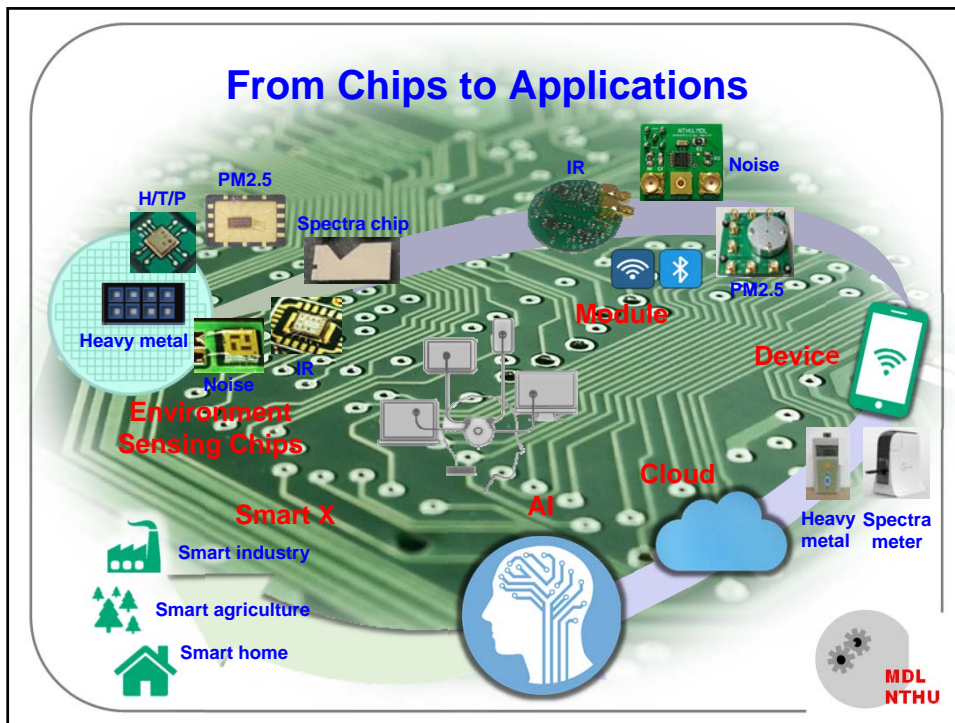


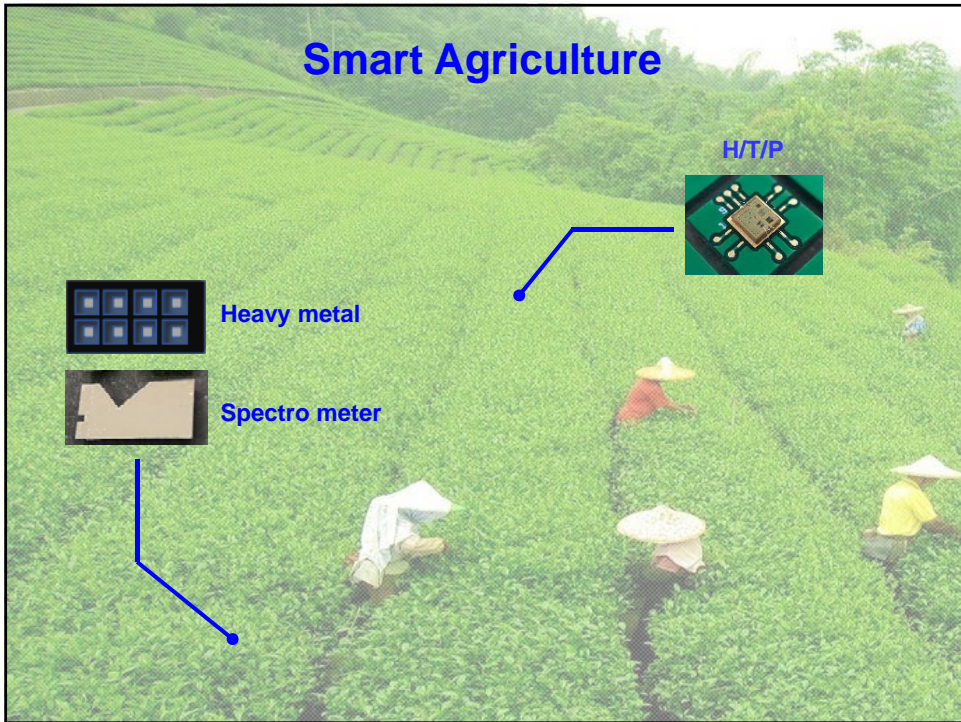
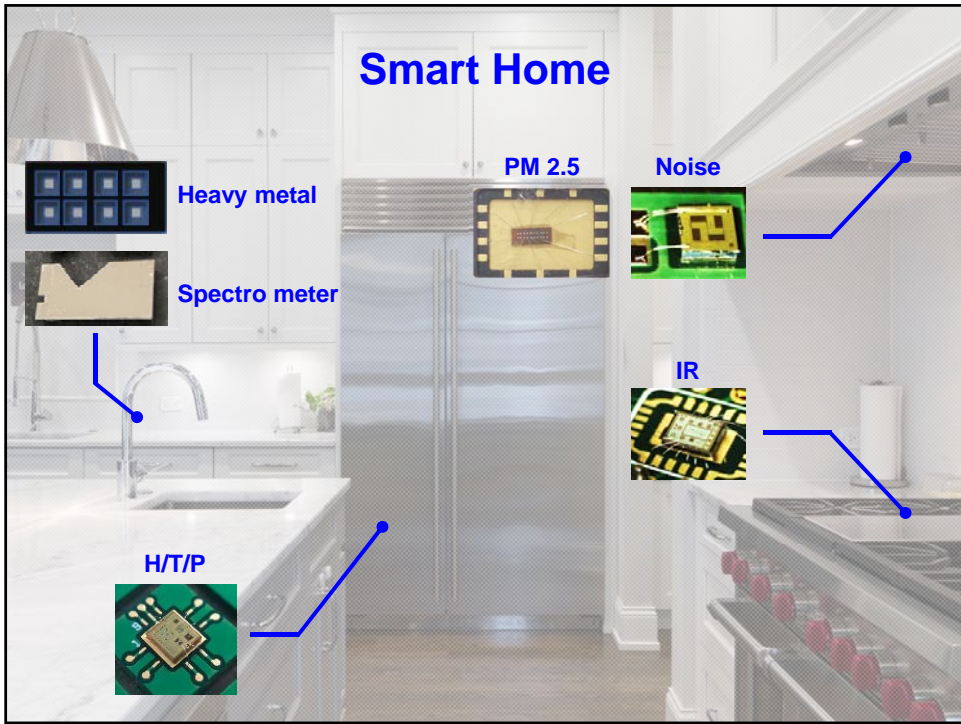
Ecosystems for IoT

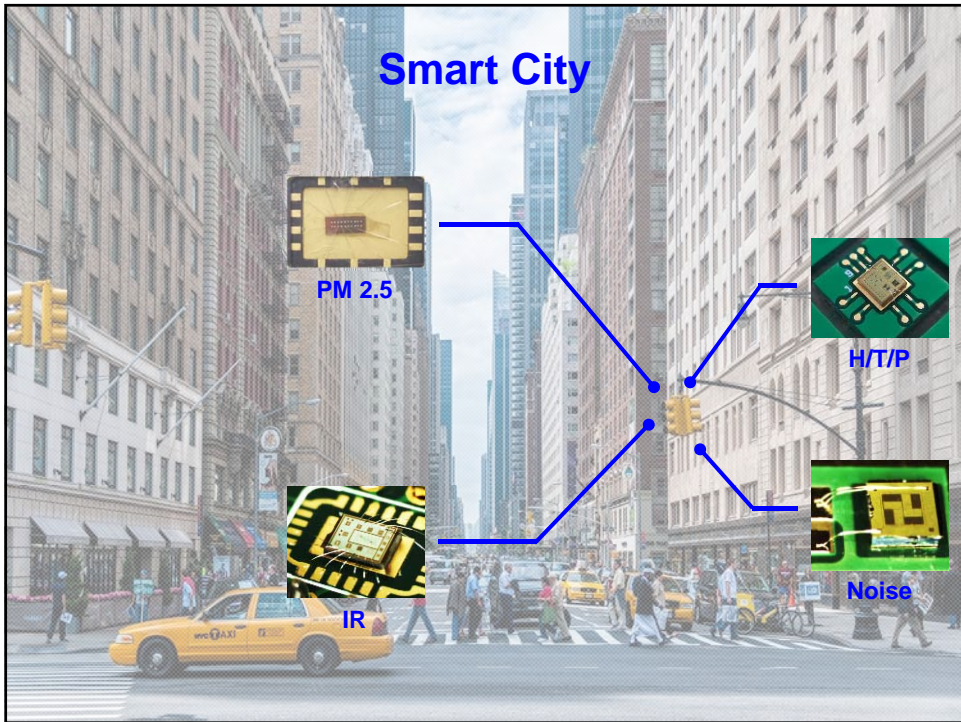
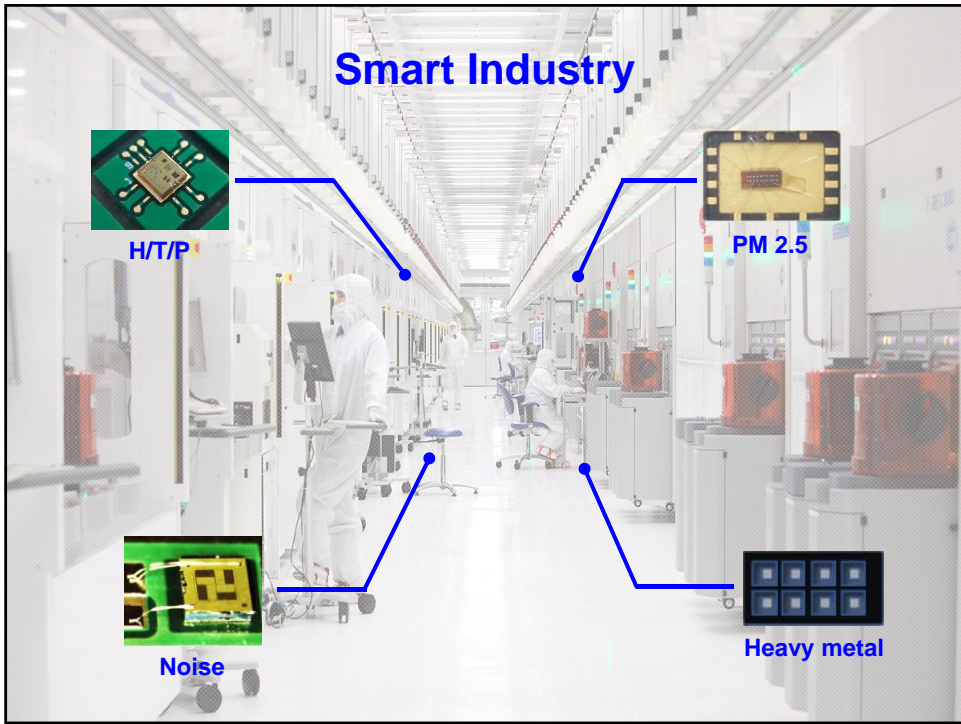


STMicroelectronics









IoT – the Next Big Things

- The next big things
 - + Highlight by Dr. Morris Chang of TSMC in 2014
 - + Major players: Google, Apple, Cisco, Alibaba, Huawei, etc.
 - + Semiconductor remain the key enabling tech.

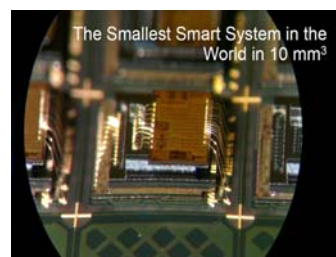


www.appledaily.com.tw



Semiconductor: Key Tech for IoT

- Key Techs for IoT
 - + MEMS and Sensors
 - + Advanced packaging
 - + Ultra low power



課程安排



Semiconductor processes

